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# Type-II BiVO<sub>4</sub>/Ni<sub>3</sub>(hexahydroxytriphenylene)<sub>2</sub> heterojunction photoanodes for effective photoelectrochemical reaction<sup>†</sup>

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Semiconducting M<sub>3</sub>(hexahydroxytriphenylene)<sub>2</sub> (M = Ni, Co, Cu; hexahydroxytriphenylene (HHTP)) was uniformly coated onto BiVO<sub>4</sub> thin films via a facile solvothermal process, and the photoelectrochemical performance of the  $BiVO_4/M_3(HHTP)_2$  photoanodes was investigated. All three  $BiVO_4/M_3(HHTP)_2$ photoanodes exhibited higher photocurrent densities than pristine  $BiVO_4$ . This can be attributed to the formation of type-II heterojunctions, as confirmed by ultraviolet photoelectron spectroscopy (UPS) and ultraviolet-visible spectroscopy.  $BiVO_4/Ni_3(HHTP)_2$  exhibited the highest photocurrent density of 4.66 mA cm<sup>-2</sup> at 1.23 V vs. a reversible hydrogen electrode (RHE), an approximately 3.2-fold increase from that of pristine BiVO<sub>4</sub>. The results suggest that the type of metal ion in M<sub>3</sub>(HHTP)<sub>2</sub> affects the electrical conductivity, which significantly influences the charge transport kinetics in the BiVO<sub>4</sub>. The mechanism photoelectrochemical reactions of underlying the enhanced photoelectrochemical reaction was also investigated.

# Introduction

Hydrogen fuel is a sustainable energy source that can be used as an alternative to fossil fuels. Photoelectrochemical water splitting is an environment-friendly method to produce hydrogen from water by utilizing solar energy. This method has drawn significant attention owing to its potential for negligible greenhouse gas emissions. Among the diverse metal oxide photoanodes used for photoelectrochemical water splitting,<sup>1,2</sup> BiVO<sub>4</sub> is a promising candidate because of its 2.4-2.5 eV bandgap, which is advantageous for absorbing visible light. However, its sluggish charge transfer kinetics and short hole diffusion length hamper charge transport and separation.<sup>3</sup> Accordingly, various methods have been considered to improve the photoelectrochemical performance of BiVO<sub>4</sub>, including area expansion, doping, and heterostructure surface design.4-8

The rational design of a type-II heterojunction with another semiconductor is a promising strategy to enhance the photoelectrochemical performance of BiVO<sub>4</sub>.<sup>9-12</sup> A type-II heterojunction established between two different semiconductors facilitates the separation of photogenerated charge carriers, preventing charge recombination losses. Because a staggered band alignment is required, it is important to consider both the

energy bandgap and band positions of the two semiconductors. The light absorption rate is determined by the energy bandgap, oxygen evolution reaction (OER), or hydrogen evolution reaction (HER) based on the band positions. Various heterostructures with staggered band alignments have been proposed to compensate for the sluggish OER, such as WO<sub>3</sub>/BiVO<sub>4</sub>,<sup>5</sup> TiO<sub>2</sub>/ BiVO<sub>4</sub>,<sup>6</sup> and BiVO<sub>4</sub>/MoS<sub>2</sub>;<sup>7</sup> however, further enhancement of the photoelectrochemical performance is required.

In recent years, heterojunctions between metal-organic frameworks (MOFs) and BiVO<sub>4</sub>, such as BiVO<sub>4</sub>/CoNi-MOF,<sup>13</sup> BiVO<sub>4</sub>/MIL-53(Fe),<sup>14</sup> and BiVO<sub>4</sub>/MIL-101(Fe),<sup>15</sup> have been investigated to improve the photoelectrochemical performance. The design and application of MOFs for photoelectrochemical reactions have been widely investigated because MOFs provide advantages such as extremely high surface area, tunable porosity, and compositional diversity and exhibit semiconducting properties. Semiconducting MOFs with suitable band structures and high electrical conductivity are promising platforms for designing photoanodes with staggered band alignments.<sup>16</sup> Among various MOFs,  $M_3$ (HHTP)<sub>2</sub> (M = Ni, Co, and Cu; 2,3,6,7,10,11-hexahydroxytriphenylene (HHTP)) has shown good electrical conduction through  $\pi$ - $\pi$  stacked pathways as well as suitable bandgaps for water splitting.<sup>17</sup> Because of their conductive nature, M<sub>3</sub>(HHTP)<sub>2</sub> photoanodes are expected to exhibit high photoelectrochemical performance. However, to the best of our knowledge, the heterojunction between BiVO<sub>4</sub> and  $M_3$ (HHTP)<sub>2</sub> for photoelectrochemical reactions has yet to be investigated.



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#### Paper

Herein, we report the highly efficient photoelectrochemical reaction of a BiVO<sub>4</sub>/M<sub>3</sub>(HHTP)<sub>2</sub> photoanode. The BiVO<sub>4</sub> film was coated onto fluorine doped tin oxide (FTO)/glass substrates by electrodeposition, then the  $M_3(HHTP)_2$  was coated onto the BiVO<sub>4</sub> film via a solvothermal reaction. All BiVO<sub>4</sub>/M<sub>3</sub>(HHTP)<sub>2</sub> photoanodes showed significantly higher photocurrent densities than pristine BiVO<sub>4</sub>, which is attributed to the type-II heterojunctions established between  $BiVO_4$  and  $M_3(HHTP)_2$ . Notably, BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> exhibited the highest photocurrent density of 4.66 mA cm<sup>-2</sup>, which is a 3.2-fold increase in efficiency from that of pristine BiVO<sub>4</sub>. This study reveals that the electrical conductivity of  $M_3(HHTP)_2$  is dependent on the type of metal ions, which play a key role in the charge transport for photoelectrochemical reactions. The main purpose of this study is to determine the key parameters affecting the OER in BiVO<sub>4</sub>/M<sub>3</sub>(HHTP)<sub>2</sub> heterostructure photoanodes and to understand the mechanism underlying the enhanced photoelectrochemical reaction.

## Experimental

#### Sample preparation

BiVO<sub>4</sub> nanoparticles were coated onto FTO/glass substrates by a modified electrodeposition method.<sup>18,19</sup> The typical synthesis process includes an FTO/glass substrate, platinum (Pt) mesh, and Ag/AgCl/saturated NaCl as the working, counter, and reference electrodes, respectively. The precursor solution for BiVO<sub>4</sub> electrodeposition was prepared as follows. 1.141 g of vanadium oxide sulfate hydrate (VOSO<sub>4</sub>·*x*H<sub>2</sub>O, 99.9%, Alfa Aesar), and 0.97014 g of bismuth nitrate pentahydrate (Bi(NO<sub>3</sub>)<sub>3</sub>·5H<sub>2</sub>O, 98.0%, Junsei) were dissolved in an aqueous

HNO<sub>3</sub> solution (100 mL, 1:9 (v/v) mixture of 60% HNO<sub>3</sub> and deionized (DI) water) under magnetic stirring to form a clear solution. A stabilizer solution was prepared by dissolving 32.812 g of sodium acetate in 100 mL of DI water, and then added to the Bi/V ion solution. The pH of the solution for electrodeposition was adjusted to 4.7. This mildly acidic pH solution is required for electrodeposition because no film can be deposited at pH values, in which Bi ions are soluble (pH < 2). Excessive precipitates hinder the film deposition at pH >  $5.^{19}$  Electrodeposition was performed at 0.8 V for 1 h at room temperature. The prepared substrates were rinsed with DI water and annealed at 550 °C for 3 h.

 $Ni_3(HHTP)_2$  was coated onto the BiVO<sub>4</sub> film *via* a solvothermal reaction. 2.5 mmol of nickel acetate tetrahydrate (Ni(OCOCH<sub>3</sub>)<sub>2</sub>·4H<sub>2</sub>O, 98.0%, Merck) was dissolved in 20 mL of DI water, and 1.25 mmol of 2,3,6,7,10,11-hexahydroxytriphenylene (HHTP, 95.0%, Acros Organics) was dissolved in 10 mL methanol. The two solutions were mixed and homogenized by stirring. Then, the mixed solution was placed in a Teflon-lined stainless-steel autoclave with a BiVO<sub>4</sub>/FTO/glass substrate immersed in it. The sealed autoclave was heated to 85 °C for 3.5 h. The substrates were rinsed with DI water thrice.

# **Results & discussion**

A schematic of the procedure for preparing the BiVO<sub>4</sub>/ $Ni_3(HHTP)_2$  heterojunction on an FTO/glass substrate is shown in Fig. 1. The BiVO<sub>4</sub> thin film was anodically electrodeposited onto the FTO/glass substrate using an aqueous solution containing Bi(m) ions and V(rv) ions. This was followed by heat treatment at 500 °C for 2 h to achieve crystalline BiVO<sub>4</sub>. The



Fig. 1 Schematic diagram of the synthesis process for the BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> heterostructure on FTO/glass substrate.

BiVO<sub>4</sub> thin film appeared as bright yellow (Fig. S1a, ESI<sup>†</sup>). The X-ray diffraction (XRD) pattern showed that the crystalline peaks are monoclinic BiVO<sub>4</sub> (Fig. S1b, ESI<sup>†</sup>). The scanning electron microscopy (SEM) images of the BiVO<sub>4</sub> thin film (Fig. S2a and b, ESI<sup>†</sup>) revealed that the film consists of large grains ranging from 100 to 500 nm with a thickness of 250–300 nm. The transmission electron microscopy (TEM) image and selected area electron diffraction (SAED) patterns of BiVO<sub>4</sub> confirmed its crystalline structure. The inter-planar spacing in the lattice fringes was analyzed to be  $d_{(040)} = 2.90 \pm 0.1$  Å (Fig. S2c, ESI<sup>†</sup>), which corresponds to the monoclinic BiVO<sub>4</sub>. Elemental mapping further confirmed that the Bi and V components were uniformly distributed along the whole grains (Fig. S2(d1)–S4, ESI<sup>†</sup>).

 $Ni_3(HHTP)_2$  was coated onto the surface of BiVO<sub>4</sub> by a solvothermal reaction at 85 °C for 3.5 h (Fig. 2a and b). The solvothermal reaction enables the conformal, well-attached, and uniform growth of  $Ni_3(HHTP)_2$  on the BiVO<sub>4</sub> surface. This is desirable in photoelectrochemical reactions because the strong adhesion between the BiVO<sub>4</sub> and MOF ensures high stability. The color of the photoanode changed from bright yellow to dark green after the solvothermal growth of  $Ni_3(HHTP)_2$  on the BiVO<sub>4</sub> thin film (Fig. 2c). Close examination of the high-resolution TEM (Fig. 2d) and elemental mapping (Fig. 2e1–6) confirmed that the  $Ni_3(HHTP)_2$  layer (150–200 nm

thickness) was uniformly coated onto the BiVO4 surface. Owing to the XRD detection limit and the negligible number of MOFs, Ni<sub>3</sub>(HHTP)<sub>2</sub> peaks were not observed in the XRD patterns (Fig. S3a, ESI<sup> $\dagger$ </sup>). To prepare a sufficient amount of Ni<sub>3</sub>(HHTP)<sub>2</sub>, the solvothermal reaction time was increased to 6 h. The detected peaks of MOF at  $2\theta = 5-20^{\circ}$  were in agreement with those observed in the simulated XRD patterns of Ni<sub>3</sub>(HHTP)<sub>2</sub> (Fig. S3b, ESI<sup>†</sup>), confirming the formation of Ni<sub>3</sub>(HHTP)<sub>2</sub> via the solvothermal reaction.<sup>20-22</sup> Furthermore, the atomic composition of the  $BiVO_4/M_3(HHTP)_2$  (M = Ni, Co, Cu) was analyzed by XPS (Fig. S4-S6, ESI<sup>+</sup>), and the existence of all the elements was confirmed by peak analysis. To examine the influence of the solvothermal reaction time on the growth of Ni<sub>3</sub>(HHTP)<sub>2</sub> on the BiVO<sub>4</sub> surface, the reaction time was controlled up to 1 h and 6 h. As the MOF precursor solution containing nickel ions and HHTP ligands induced rapid nucleation and growth at the initial stage, the morphology of Ni<sub>3</sub>(HHTP)<sub>2</sub> after the 1 h and 3.5 h solvothermal reactions appeared to be similar (Fig. S7a, b, ESI<sup>†</sup> and Fig. 2a, b). However, when the solvothermal reaction time increased to 6 h, a thick  $Ni_3(HHTP)_2$  layer (4-5  $\mu$ m) unevenly covered the BiVO<sub>4</sub> film (Fig. S7c and d, ESI<sup>+</sup>). An excessively thick Ni<sub>3</sub>(HHTP)<sub>2</sub> layer will affect the charge transfer within the Ni<sub>3</sub>(HHTP)<sub>2</sub>, which would deteriorate photoelectrochemical reaction. Hence, the thickness of Ni<sub>3</sub>(HHTP)<sub>2</sub> should be optimized by controlling the solvothermal reaction time.



Fig. 2 (a) Top-view and (b) cross-sectional view of the SEM image of  $BiVO_4/Ni_3(HHTP)_2$  heterostructure (solvothermal reaction for 3.5 h). (c) Photograph of  $BiVO_4/Ni_3(HHTP)_2$  heterostructure photoanode. (d) TEM image and (e1–6) elemental mappings of  $BiVO_4/Ni_3(HHTP)_2$  heterostructure.

The photocurrent densities of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> were evaluated in both 0.1 M Na<sub>2</sub>SO<sub>3</sub> and 0.1 M Na<sub>2</sub>SO<sub>4</sub> solution under front and back illumination (Fig. 3a). In BiVO<sub>4</sub> photoanodes with sluggish charge transport kinetics, backside illumination led to a higher photocurrent density than frontside illumination because it allows the more efficient collection of photogenerated electrons.<sup>23,24</sup> In the present study, holescavenging Na<sub>2</sub>SO<sub>3</sub> was used to suppress the surface recombination of BiVO<sub>4</sub>.<sup>25</sup> At the potential of 1.23 V vs. RHE, BiVO<sub>4</sub> under front and back illumination showed photocurrent densities of 1.09 mA  $cm^{-2}$  and 1.42 mA  $cm^{-2}$ , respectively. When Ni<sub>3</sub>(HHTP)<sub>2</sub> was solvothermally coated onto BiVO<sub>4</sub> for 3.5 h, the photocurrent density significantly increased to 3.45 and 4.66 mA cm<sup>-2</sup> under front and back illumination, respectively, which is approximately 3.2 times higher than that of a pristine BiVO<sub>4</sub> photoanode. When the solvothermal reaction time reached 6 h, however, the photocurrent density of BiVO<sub>4</sub>/ Ni<sub>3</sub>(HHTP)<sub>2</sub> significantly decreased, probably because of ineffective charge transport through the extremely thick MOF layer (Fig. S8, ESI<sup>†</sup>). The photocurrent density of BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> reached 3.10 mA cm<sup>-2</sup> at 1.23 V vs. RHE in 0.1 M Na<sub>2</sub>SO<sub>4</sub> electrolyte (without hole-scavenging Na<sub>2</sub>SO<sub>3</sub>), suggesting that Ni<sub>3</sub>(HHTP)<sub>2</sub> is also a promising catalyst for photoelectrochemical water splitting (Fig. S9, ESI<sup>†</sup>). It is worth noting that the photocurrent density of the BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> photoanode is

similar to or greater than that of previous BiVO4-based heterojunction photoanodes in the literature (Table S1, ESI<sup>†</sup>). Besides,  $BiVO_4/Ni_3(HHTP)_2$  showed an abrupt slope change above 1.1 V vs. RHE with or without the presence of Na<sub>2</sub>SO<sub>3</sub>. The *J*-V curves shown in Fig. S10 (ESI<sup>+</sup>) revealed that the current density of BiVO<sub>4</sub> did not significantly increase in the dark, while Ni<sub>3</sub>(HHTP)<sub>2</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> have a different increasing trend above 1.1 V vs. RHE. Therefore, the unusual increasing trend could be attributed to an intrinsic catalytic activity of Ni<sub>3</sub>(HHTP)<sub>2</sub>. The light on/off cycles of BiVO<sub>4</sub> and BiVO<sub>4</sub>/  $Ni_3$ (HHTP)<sub>2</sub> were obtained by applying the constant potential of 1.23 V vs. RHE (Fig. 3b). Both photoanodes exhibited rapid photoresponses under initial illumination, followed by a stable steady-state, and were highly reproducible for a few cycles. The incident photon-to-electron conversion efficiency (IPCE) spectra were examined from 300 to 800 nm at 1.23 V vs. RHE to investigate the light absorption and energy conversion efficiency of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> (Fig. 3c). BiVO<sub>4</sub>/ Ni<sub>3</sub>(HHTP)<sub>2</sub> reached the highest IPCE of 83.4% at  $\lambda$  = 460 nm, which is almost four times higher than that of pristine BiVO<sub>4</sub>. The IPCE value significantly increased throughout the entire range, indicating that Ni<sub>3</sub>(HHTP)<sub>2</sub> promoted the effective utilization of visible light. Electrochemical impedance spectroscopy (EIS) of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> was conducted at 1.23 V vs. RHE to examine the surface resistance and charge transport



**Fig. 3** (a) J-V curves of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> (front and back illumination) in a 0.1 M Na<sub>2</sub>SO<sub>3</sub> electrolyte. (b) Light on/off current density transients of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> (front and back illumination) at 1.23 V vs. RHE. (c) IPCE measurements of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub>. (d) EIS analysis for BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> (front and back illumination).

 Table 1
 Fitted charge transfer resistance

Photoanode	$R_{\rm s} \left( \Omega \ {\rm cm}^2 \right)$	$R_{\rm ct} \left(\Omega \ {\rm cm}^2\right)$
BiVO <sub>4</sub> (front)	17.3	1740
BiVO <sub>4</sub> (back)	17.7	909.5
$BiVO_4/Ni_3(HHTP)_2$ (front)	8.5	665.3
BiVO <sub>4</sub> /Ni <sub>3</sub> (HHTP) <sub>2</sub> (back)	7.4	447.9

during photoelectrochemical reactions (Fig. 3d). The obtained Nyquist plots were fitted and simulated to determine the  $R_{ct}$ values (charge transfer resistance at the interface between the photoanode and electrolyte) listed in Table 1. An equivalent circuit for the EIS results is shown in the inset of Fig. 3d. According to the fitted charge transfer resistance, backilluminated BiVO4 and BiVO4/Ni3(HHTP)2 exhibited lower resistance than front-illuminated photoanodes. The results indicate that backside illumination is advantageous for collecting photogenerated electrons and can overcome the sluggish charge transport kinetics of BiVO<sub>4</sub>. Moreover, additional EIS measurements (Fig. S11a, ESI<sup>+</sup>) were conducted in the dark at 0 V to confirm a junction formed between BiVO4 and Ni<sub>3</sub>(HHTP)<sub>2</sub>. Without any external bias and light energy, the EIS spectra of BiVO4 revealed one semicircle, while BiVO4/  $Ni_3(HHTP)_2$  revealed two semicircles. When  $Ni_3(HHTP)_2$ formed a junction with BiVO<sub>4</sub>, the R<sub>ct</sub> values decreased from 909.5  $\Omega$  cm<sup>2</sup> to 447.9  $\Omega$  cm<sup>2</sup>, indicating a facilitated charge transfer through the BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> and electrolyte interface. In addition, the charge carrier concentration  $(N_{\rm D})$  was calculated using Mott-Schottky analysis (Fig. S11b, ESI†). According to the Mott-Schottky plot, N<sub>D</sub> can be calculated using the following equation:<sup>26</sup>

$$N_{\rm D} = \frac{2}{e\varepsilon_0\varepsilon} \times \left[ \frac{\mathrm{d} \left[ \frac{1}{C^2} \right]}{\mathrm{d} V_{\rm s}} \right]^{-1}, \qquad (1)$$

where *e* is the electronic charge  $(1.6 \times 10^{-19} \text{ C})$ ,  $\varepsilon_0$  is the vacuum permittivity (8.854 × 10<sup>-12</sup> F m<sup>-1</sup>),  $\varepsilon$  is the relative permittivity of BiVO<sub>4</sub> (68),<sup>27</sup> C (F cm<sup>-2</sup>) is the space charge capacitance, and  $V_{\rm s}$  (V) is the applied potential. The obtained  $N_{\rm D}$  values for BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> were 1.86 × 10<sup>16</sup> cm<sup>-3</sup> and 3.03 × 10<sup>16</sup> cm<sup>-3</sup>, respectively. The results indicated that higher charge carrier concentration is generated through the heterojunction formed between BiVO<sub>4</sub> and Ni<sub>3</sub>(HHTP)<sub>2</sub>, implying that Ni<sub>3</sub>(HHTP)<sub>2</sub> was highly effective at promoting charge carrier transport.

 $Co_3(HHTP)_2$  and  $Cu_3(HHTP)_2$  are two other potential conductive MOFs<sup>28</sup> that were coated onto BiVO<sub>4</sub> by a solvothermal reaction to investigate their photoelectrochemical performance. Upon their use, the photocurrent density increased to 2.25 and 1.77 mA cm<sup>-2</sup> (Fig. S12a, ESI<sup>†</sup>). The IPCE values of BiVO<sub>4</sub>/Co<sub>3</sub>(HHTP)<sub>2</sub> and BiVO<sub>4</sub>/Cu<sub>3</sub>(HHTP)<sub>2</sub> were more than twice that of with pristine (Fig. S12b, ESI<sup>†</sup>). The fitted  $R_{ct}$  values decreased as  $Co_3(HHTP)_2$  and  $Cu_3(HHTP)_2$  were coated onto BiVO<sub>4</sub> (Fig. S12c, d and Table S2, ESI<sup>†</sup>). The results confirm that the formation of a heterostructure photoanode between

semiconducting HHTP-based MOFs and BiVO4 could enhance photoelectrochemical reactions.<sup>29-33</sup> Although Co<sub>3</sub>(HHTP)<sub>2</sub> and Cu<sub>3</sub>(HHTP)<sub>2</sub> improved the photoelectrochemical activity of BiVO<sub>4</sub>, its efficiency was lower than that of BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub>. The higher electrochemical performance of Ni<sub>3</sub>(HHTP)<sub>2</sub> can be understood in terms of its high electrical conductivity among the three HHTP-based MOFs. To examine this, porous  $M_3$ (HHTP)<sub>2</sub> pellets were prepared (Fig. S13a, ESI<sup>†</sup>), and their electrical conductivities were measured using the two-electrode method. The conductivities are  $\sigma = 4.45 \times 10^{-6} \text{ S cm}^{-1}$ ,  $1.59 \times 10^{-7}$  S cm<sup>-1</sup>, and  $4.29 \times 10^{-8}$  S cm<sup>-1</sup> for Ni<sub>3</sub>(HHTP)<sub>2</sub>, Co<sub>3</sub>(HHTP)<sub>2</sub>, and Cu<sub>3</sub>(HHTP)<sub>2</sub>, respectively (Fig. S13b, ESI<sup>†</sup>). The conductivity of Ni<sub>3</sub>(HHTP)<sub>2</sub> is significantly higher than those of Co<sub>3</sub>(HHTP)<sub>2</sub> and Cu<sub>3</sub>(HHTP)<sub>2</sub>, even considering the small variation in densities, which is in line with the reported results.<sup>17</sup> For  $M_3(HHTP)_2$ , the electrical conductivity is dependent on the type of metal ion with different electronic states.<sup>34</sup> Moreover, as M<sub>3</sub>(HHTP)<sub>2</sub> frameworks are built in stacked twodimensional (2D) structures, the interlayer spacing (S) along the *c* direction also influences the conduction. In general, a higher S value with a lower strength of interaction between the 2D layers yields a higher conductivity.<sup>35</sup> In the literature,  $Ni_3$ (HHTP)<sub>2</sub> was reported to have the highest S value (3.8 Å),<sup>36</sup> while Cu<sub>3</sub>(HHTP)<sub>2</sub> had the lowest (3.16 Å) among the three MOFs.<sup>17</sup> The conductivity values in the present study and literature suggest that the high conductivity of Ni<sub>3</sub>(HHTP)<sub>2</sub> plays a key role in the superior photoelectrochemical performance of the BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> photoanode.

To reveal the dynamics of light absorption, charge separation, and charge transfer, the intrinsic band structures of BiVO<sub>4</sub> and Ni<sub>3</sub>(HHTP)<sub>2</sub> were investigated using ultraviolet photoelectron spectroscopy (UPS) and ultraviolet-visible (UV-vis) spectroscopy. Fig. 4a and b show the UPS of BiVO<sub>4</sub> and Ni<sub>3</sub>(HHTP)<sub>2</sub> for obtaining the work function ( $\phi$ , energy from vacuum level to Fermi level) and valence band maximum (VBM, energy from Fermi level to valence band maximum). The work functions of BiVO<sub>4</sub> and Ni<sub>3</sub>(HHTP)<sub>2</sub> are 4.20 eV and 5.0 eV, while the VBM values are 2.25 eV and 1.62 eV, respectively. The UV-vis spectra in Fig. 4c shows that the energy bandgaps of BiVO4 and Ni<sub>3</sub>(HHTP)<sub>2</sub> were 2.50 and 2.68 eV, respectively. The intrinsic band structures of BiVO<sub>4</sub> and Ni<sub>3</sub>(HHTP)<sub>2</sub> are shown in Fig. 4d. As BiVO<sub>4</sub> has a higher  $E_F$  than Ni<sub>3</sub>(HHTP)<sub>2</sub>, the electrons would transfer from BiVO4 to Ni3(HHTP)2 until equilibrium is reached. After the electronic state reached equilibrium, the band structure caused the upward band edge bending of BiVO<sub>4</sub>, and downward band edge bending of  $Ni_3(HHTP)_2$ , forming a type-II heterojunction. In the type-II heterojunction established in BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub>, the photogenerated electrons migrated from the conduction band  $(E_{\rm C})$  of Ni<sub>3</sub>(HHTP)<sub>2</sub> to the  $E_{\rm C}$  of BiVO<sub>4</sub>. In contrast, the photogenerated holes migrated from the valence band  $(E_V)$  of BiVO<sub>4</sub> to the  $E_V$  of Ni<sub>3</sub>(HHTP)<sub>2</sub>, facilitating the separation of photogenerated charge carriers (Fig. 4e). In addition, the intrinsic band structures of Co<sub>3</sub>(HHTP)<sub>2</sub> and Cu<sub>3</sub>(HHTP)<sub>2</sub> were investigated to understand the bandbending between BiVO<sub>4</sub>/Co<sub>3</sub>(HHTP)<sub>2</sub> and BiVO<sub>4</sub>/Cu<sub>3</sub>(HHTP)<sub>2</sub> (Fig. S14 and S15, ESI<sup>†</sup>). Both BiVO<sub>4</sub>/Co<sub>3</sub>(HHTP)<sub>2</sub> and BiVO<sub>4</sub>/



Fig. 4 UPS of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> for obtaining (a) work function (f) and (b) VBM. (c) UV-vis spectra of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub>. Schematic energy band diagram of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> (d) before contact and (e) after contact.

 $Cu_3$ (HHTP)<sub>2</sub> achieved the type-II heterojunction after reaching equilibrium. The band-bending structure is in line with the photoelectrochemical activities, indicating that the coating with HHTP-based MOFs promotes effective charge separation for the efficient photoelectrochemical performance of BiVO<sub>4</sub>. The results validate the high versatility of HHTP-based MOFs along with the enhanced photoelectrochemical activities of BiVO<sub>4</sub>/HHTP-based MOF heterostructure photoanodes.

Aside from band-bending diagrams of BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub>, it is crucial to examine the three critical factors affecting the photoelectrochemical activity: light absorption efficiency ( $\eta_{abs}$ ), charge separation efficiency ( $\eta_{sep}$ ), and charge transfer efficiency ( $\eta_{trans}$ ). The three factors are expressed in the following water oxidation equation:<sup>37–39</sup>

$$J_{\text{water}} = J_{\text{max}} \times \eta_{\text{abs}} \times \eta_{\text{sep}} \times \eta_{\text{trans}}$$
(2)



Fig. 5 (a) Light harvesting efficiency (LHE) (%) and (b) charge separation efficiency ( $\eta_{sep}$ ) of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub>.

where  $J_{\rm max}$  is the theoretical maximum photocurrent density, and  $J_{\rm water}$  is the experimentally obtained photocurrent density. To simplify the equation,  $\eta_{\rm trans}$  can be assumed as 100% when the hole scavenger (Na<sub>2</sub>SO<sub>3</sub>) that induces rapid oxidation kinetics is present in the electrolyte.

$$J_{\text{sulfite}} = J_{\text{max}} \times \eta_{\text{abs}} \times \eta_{\text{sep}} \tag{3}$$

If it is assumed that all the absorbed photons are fully converted to photocurrent density, the  $\eta_{sep}$  and  $\eta_{trans}$  can be neglected. The equation can be further simplified as follows:

$$J_{\rm abs} = J_{\rm max} \times \eta_{\rm abs} \tag{4}$$

Light absorption was observed at 496 nm and 504 nm for BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub>, respectively (Fig. 5a). By integrating the electron flux of both air mass (AM) 1.5G and the photoanode, as shown in Fig. S16a and b (ESI<sup> $\dagger$ </sup>), the  $J_{max}$  of BiVO<sub>4</sub> and BiVO<sub>4</sub>/  $Ni_3$ (HHTP)<sub>2</sub> are 6.44 mA cm<sup>-2</sup> and 6.95 mA cm<sup>-2</sup>, while the  $J_{abs}$ are 4.42 mA cm<sup>-2</sup> and 4.89 mA cm<sup>-2</sup>, respectively (Table S3, ESI<sup>†</sup>). The  $\eta_{abs}$  of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> were calculated as 68.6% and 70.4%, respectively. Although BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> yielded higher  $\eta_{abs}$  than BiVO<sub>4</sub>, the enhancement was not significant because Ni<sub>3</sub>(HHTP)<sub>2</sub> has a bandgap of 2.68 eV, which is slightly larger than that of  $BiVO_4$  (2.50 eV). The  $\eta_{\rm abs} \times \eta_{\rm sep}$  of BiVO<sub>4</sub> and BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> were obtained by eliminating the  $\eta_{\text{trans}}$  (Fig. S16c, ESI<sup>†</sup>). Consequently, with the known  $\eta_{abs}$ , the  $\eta_{sep}$  of the photoanodes was calculated, as shown in Fig. 5b. When Ni<sub>3</sub>(HHTP)<sub>2</sub> was coated onto BiVO<sub>4</sub>, the  $\eta_{\text{sep}}$  significantly increased to 51.4%, which is 2.1 times higher than that of pristine BiVO4 film. These results show that establishing a type-II heterojunction between Ni<sub>3</sub>(HHTP)<sub>2</sub> and BiVO<sub>4</sub> promotes effective charge separation, which ultimately improves the photoelectrochemical performance of the photoanodes. The long-term stability of the BiVO4 and BiVO4/ Ni<sub>3</sub>(HHTP)<sub>2</sub> photoanodes was also examined for 40 000 s at 1.23 V vs. RHE (Fig. S17, ESI†). No severe degradation was observed, and the results indicate that BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> was electrochemically stable over a long period. In addition, the structure of BiVO<sub>4</sub>/Ni<sub>3</sub>(HHTP)<sub>2</sub> after photoelectrochemical reactions was observed by TEM and elemental mappings (Fig. S18, ESI<sup>†</sup>). The adhesion between BiVO<sub>4</sub> and Ni<sub>3</sub>(HHTP)<sub>2</sub> was strong enough to maintain its stable structure even after photoelectrochemical reactions.

### Conclusions

BiVO<sub>4</sub>/M<sub>3</sub>(HHTP)<sub>2</sub> heterojunction photoanodes with three different metal ions (M = Ni, Co, and Cu) were prepared *via* facile electrodeposition followed by a solvothermal process for photoelectrochemical reactions. The M<sub>3</sub>(HHTP)<sub>2</sub> coating is aimed at improving the sluggish charge transport kinetics of BiVO<sub>4</sub> by forming staggered band alignments. All three BiVO<sub>4</sub>/ M<sub>3</sub>(HHTP)<sub>2</sub> photoanodes exhibited higher photocurrent densities than the pristine BiVO<sub>4</sub> film; type-II heterojunctions were observed between BiVO<sub>4</sub> and M<sub>3</sub>(HHTP)<sub>2</sub>. Effective light absorption and charge separation were achieved through the type-II heterojunctions, which were confirmed by UPS and UV-vis spectroscopy. In particular,  $BiVO_4/Ni_3(HHTP)_2$  had the highest photocurrent density of 4.66 mA cm<sup>-2</sup>, which is 3.2 times greater than that of pristine  $BiVO_4$ . Among the three types of  $M_3(HHTP)_2$ ,  $Ni_3(HHTP)_2$  exhibited the highest bulk conductivity, indicating that the electrical conductivity of MOF and the type-II band alignment significantly influenced the photoelectrochemical performance. This study demonstrates that establishing a type-II heterojunction between semiconducting  $M_3(HHTP)_2$  and  $BiVO_4$  is a promising and general strategy for obtaining high-performance photoanodes.

# Conflicts of interest

There are no conflicts to declare.

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